

GEMOLOGICAL INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

PROPORTIONS

CLARITY CHARACTERISTICS

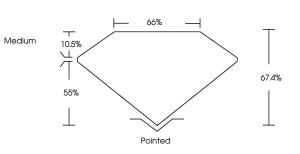
KEY TO SYMBOLS

Red symbols indicate internal characteristics. Green symbols indicate external characteristics.

| May 23, 2024 | | | | | |
|--------------------------------|--------------------------|--|--|--|--|
| IGI Report Number | LG635422152 | | | | |
| Description | LABORATORY GROWN DIAMOND | | | | |
| Shape and Cutting Style | PRINCESS CUT | | | | |
| Measurements | 7.85 X 7.66 X 5.16 MM | | | | |
| GRADING RESULTS | | | | | |
| Carat Weight | 2.70 CARATS | | | | |
| Color Grade | D | | | | |
| Clarity Grade | V\$ 2 | | | | |
| ADDITIONAL GRADING INFORMATION | | | | | |

| Polish | EXCELLENT |
|----------------|------------------|
| Symmetry | EXCELLENT |
| Fluorescence | NONE |
| Inscription(s) | 1/31 LG635422152 |

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



LG635422152

Report verification at igi.org



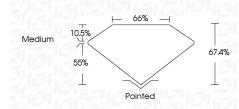
Sample Image Used

COLOR

| D E F | GHIJ | Faint | Very Light | Light |
|------------------|--------------------------|--|-------------------|------------|
| CLARITY | WS ^{1 - 2} | V\$ ¹⁻² | SI ¹⁻² | , 1-3 |
| IF Internally | Very Very | Very | Slightly | Included |
| Flawless | Slightly Included | Slightly Included | Included | Included |
| | | Contraction of the second seco | | |
| © k | GI 2020, International G | emological Institute | 10 | FD - 10 20 |
| 6 | | WITH THE FOLLOWING SECURITY MEASU M AND OTHER SECURITY FEATURES NOT LIS | | |

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